

SHEET 1 OF 1

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

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 APPLICANT
Masayuki ENDO, et al.

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U.S. PATENT DOCUMENTS

EXAMINER'S INITIALS	CITE NO.	Document Number Number-Kind Code(s) (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		US 5,880,169	03-09-1999	OSAWA et al.	Corresponds to JP 09-323970
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EXAMINER'S INITIALS	CITE NO.	Foreign Patent Document Country Code(s)-Number(s)-Kind Code(s) (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines Where Relevant Figures Appear	Translation Yes No
		JP 9-222724	08-26-1997	JAPAN SYNTHETIC RUBBER CO LTD		JAPAN (w/ Partial English Translation)
		JP 09-323970	12-16-1997	SHIN ETSU CHEM CO LTD	Corresponds to US 5,880,169	JAPAN (w/ English Abstract)
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OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)

EXAMINER'S INITIALS	CITE NO.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.
		Japanese Office Action, with English Translation, issued in Corresponding Japanese Patent Application No. 2003-177684, dated on October 30, 2007
		SWITKES et al. "Resolution Enhancement of 157 nm Lithography by Liquid Immersion", OPTICAL MICROLITHOGRAPHY XV, Proceedings of SPIE Vol. 4691, pages 459-465 March 5-8, 2002
EXAMINER /James Mitchell/		DATE CONSIDERED 03/01/2008

*EXAMINER: initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

1 Applicant's unique citation designation number (optional). 2 Applicant is to place a check mark here if English language Translation is attached.

ALL REFERENCES CONSIDERED EXCEPT WHERE LINED THROUGH. /J.m.m